

N-bridged and H-bridged aminoalanes: Singlecrystal X-ray structure determinations for the planar dimer {[(Me₃Si)₂N]₂Al(μ-H)}₂ and the puckered four-membered ring compound (Me₃Si)₂N(Me₂N)Al(μ-NMe₂)₂Al(H)N(SiMe₃)₂

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Abstract—The known bis(bis(trimethylsilyl)amino)alane $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (1) is obtained from disproportionation of the base-stabilized monomeric bis(trimethylsilyl)aminoalane $[(Me_3Si)_2NAlH_2] \cdot NMe_3$ in refluxing toluene. The single-crystal X-ray structure determination for 1 provides a H-bridged planar dimer with exo-cyclic N(SiMe_3)_2 groups. The combination of 1 with HNMe_2 in a 1:1 ratio results in competing aminolysis at the Al–H site and transamination at the Al–N(SiMe_3)_2 site of 1, as illustrated by the molecular structure of $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$ (2) which is isolated from this system. The characteristic structural feature of 2 is a puckered $\{Al–N–Al–N\}$ ring with different ligands on two aluminum atoms. \mathbb{C} 1998 Elsevier Science Ltd. All rights reserved

Keywords: alanes; trimethylsilylamines; disproportionation; transamination; aminolysis; precursors.

INTRODUCTION

In the solid state, some alane amine adducts show dimeric connectivities $[H_3Al \cdot L]_2$ (for example, $L = NMe_3$ [1], NMe_2CH_2Ph [2]) with five-coordinated aluminum atoms and somewhat counterintuitive unsymmetrical Al–H–Al bridges while, on the other hand, others seem to favor a monomeric mode with four-coordinated Al in $H_3Al \cdot L$ (for example, $L = N(n-Bu)_3$ [3], quinuclidine [4]) or five-coordinated Al having a N–Al(H₃)–N bond sequence as in trigonal bipyramidal $H_3Al \cdot 2NMe_3$ [5]. This span of bonding preferences in the alane adducts is generally interpreted as a manifestation of the ligand's steric hindrance and is not an exclusive property of amine Lewis bases. The latter is illustrated by examples of the Al– H–Al bridged dimer $[H_3Al \cdot THF]_2$ and trigonal bipyramidal $H_3Al \cdot 2THF$ with an O–Al(H_3)–O axis [6]. Even more complex bonding environments are encountered in some polymeric structures containing Al H_3 units [7]. Finally, ionic bonding is displayed by rare species of the type $(H_2AlL)^+(AlH_4)^-$ where L is a trior tetradentate amine ligand [8]. The progress in the chemistry of Lewis base adducts of alane and gallane has recently been reviewed [9].

The aminoalanes, $\{H_nAl(NR_2)_{3-n}\}$ (n=0, 1, 2), appear to exhibit similar diversity of bonding as outlined above for alane amine adducts but relatively shorter Al–N bond lengths in the former make the steric factor play a more obvious role. For example, the dimethylaminoalane, $(H_2AlNMe_2)_3$, is a Nbridged trimer in solution [10] and in the solid state [11] but both bis(dimethylamino)alane, [HAl(NMe_2)_2]_2 [12], and tris(dimethylamino)alane, [Al(NMe_2)_3]_2 [13, 14], are N-bridged dimers. Even

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larger NR2 groups may result in N-bridged dimeric cores such as found in 2,6-dimethylpiperidinoalane, [H₂Al(dmp)]₂ [15]. A further increase of the bulkiness of the piperidino ligand, in the absence of NMe₃ as in the reaction between LiAlH₄ with (tmpH) \cdot HCl, yields postulated H-bridged trimer 2,2,6,6-tetraа methylpiperidinoalane, [H₂Al(tmp)]₃, or, even in the presence of NMe₃ in the reaction between $H_3Al\cdot NMe_3$ with 2 equivalents of tmpH, gives the authenticated H-bridged dimer bis(2,2,6,6-tetramethylpiperidino)alane, [HAl(tmp)₂]₂ [15]. On the other hand, an extreme bulkiness of N(SiMe₃)₂ coupled with a latent N-basicity in this group is thought to be responsible for the kinetic stabilization of the unassociated Al[N(SiMe₃)₂]₃ [16].

In addition to the formation of the N- or H-bridged aminoalanes, stabilization of the aminoalane unit by an available Lewis base may sometimes also be favorable. In systems utilizing the convenient form of alane, H₃Al · NMe₃, trimethylamine as a potent Lewis base is found in a few cases to play that role. It was originally reported that the monomeric aminoalane, stabilized by coordination of NMe3 at the Al-site, $[H_2AlN(SiMe_3)_2] \cdot NMe_3$, was formed from the reaction between $H_3Al \cdot NMe_3$ and $HN(SiMe_3)_2$ [17, 18]. This finding was later confirmed in a parallel study, which additionally provided a structural proof for the related [H(Cl)AlN(SiMe₃)₂] · NMe₃ [19]. Further, a 1:1 ratio reaction between H₃Al·NMe₃ and tmpH afforded $[H_2Al(tmp)] \cdot NMe_3$ [20], which can be compared with the previously discussed H-bridged trimer [H₂Al(tmp)]₃ [15] obtained in the absence of trimethylamine. One should be aware that this kind of adduct stabilization extends into other group 13group 15 systems and, for example, is also found in the pnictinoalanes $[H_2AlEMes_2] \cdot NMe_3$ (E=P, As) [21] and $[H_2AlAs(SiMe_3)_2] \cdot NMe_3$ [22].

The original reports by Paine and coworkers on the preparation of $[H_2AlN(SiMe_3)_2] \cdot NMe_3$ [17, 18] indicated that thermal decomposition of this compound resulted in the formation of new bis(bis-(trimethylsilyl)amino)alane $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_n$ of an undetermined degree of oligomerization; some analytical evidence, however, supported the presence of Al-H-Al bridges in this product [18]. This was contrary to what the parallel report by Raston and coworkers claimed about the thermal behavior of [H₂AlN(SiMe₃)₂] · NMe₃ [19], namely, decomposition to elemental aluminum presumably along a reductive coupling pathway with dihydrogen evolution and, here, additionally, with concurrent release of NMe₃. In this regard, one has to be aware that reductive coupling is not the only thermally induced decomposition pathway for aminoalanes and it has long been known that their ligand disproportionation chemistry is of equal importance [12, 23]. Herein, we confirm the originally reported disproportionation of [H₂AlN(SiMe₃)₂] · NMe₃ and describe the singlecrystal X-ray diffraction study for the resulting Hbridged dimer, bis(bis(trimethylsilyl)amino)alane ${[(Me_3Si)_2N]_2Al(\mu-H)}_2$ (1). We also outline the reaction of 1 with HNMe₂ and the isolation of an unsymmetrically substituted product $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$ (2) for which a single-crystal structure is presented.

EXPERIMENTAL

General techniques

All experiments were carried out using standard vacuum/Schlenk techniques. Solvents were dried and distilled from Na benzophenone ketyl or Na/K alloy prior to use. HNMe2 was obtained from Aldrich and used as received. [H₂AlN(SiMe₃)₂]·NMe₃ and $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ were prepared by the literature methods [18]; the synthesis and characterization of the latter is also described in more detail below. ¹H and ¹³C ^{1}H NMR spectra were acquired on a Varian Unity 400 spectrometer at 25°C from toluene $d_{8}\xspace$ solutions and referenced vs $SiMe_{4}$ by generally accepted methods. Mass spectra were collected on a JEOL JMS-SX 102A spectrometer operating in the EI mode at 20 eV. IR spectra of solids and oily products were acquired using KBr pellets and NaCl plates, respectively, on a BOMEM Michelson MB-100 FT-IR spectrometer. A calibrated manifold was used for volume estimations of reaction gases. Melting behavior (uncorrected) was determined with a Thomas-Hoover Uni-melt apparatus for samples flame-sealed in glass capillaries. Single-crystal X-ray diffraction studies for 1 and 2 were performed at the Department of Chemistry and Biochemistry, University of Delaware, Newark, DE, on a Siemens P4/CCD diffractometer, using Mo Ka radiation $(\lambda = 0.71073 \text{ Å})$. All calculations were carried out with the help of SHELXTL 5.03 programs [24]; the structures were solved by direct methods.

Preparation of $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (2)

A sample of [H₂AlN(SiMe₃)₂]·NMe₃, 1.24g or 5.0 mmol, was dissolved in about 10-15 mL of toluene, stirred and refluxed overnight under nitrogen. Typically, elemental aluminum precipitated on the sides of reaction flask in the form of agglomerates but, sometimes, aluminum would form as a colloidal suspension. The mixture was concentrated by evacuation to about 5-10 mL and refluxed for an additional 24 h. Subsequently, it was filtered, the volatiles evacuated from the filtrate and the resulting residue dissolved in a few mL of hexane. The concentrated hexane solution, after storage at -30° C, afforded abundant colorless crystals of 1, 0.48 g or 55% yield based on eqn (1) (vide infra). More crystalline product could be recovered from the solution by further concentrating and repeating the low temperature crystallization. M.p. 95–97°C. ¹H NMR: δ 0.34 (36H; SiMe₃), 4.4 (1H, br; AlH). ¹³C{¹H} NMR: δ 6.0 (SiMe₃). MS: *m/e* (intensity) (ion): peak clusters around: $695 (1) (\{[(Me_3Si)_2N]_2$ $Al(\mu-H)_2 - H$ or M-H, 667 (1) (M-2Me+H), 596 (1) $(M-SiMe_3+3H)$, 552 (2) $(M-2SiMe_3+2H)$, 536 (2) $(M-N(SiMe_3)_2), 492(3)(M-N(SiMe_3)_2-3Me+H), 461$ (2) $(M-N(SiMe_3)_2-5Me)$ 421 (5) $(M-N(SiMe_3)_2-5Me)$ $SiMe_3-3Me+3H$, 347 (3) ([(Me_3Si)_2N]_2AlH-H or $M^{*}-H$, 331 (2) ($M^{*}-Me-2H$), 300 (2) ($M^{*}-3Me-3H$), 275 (3) (M*-SiMe₃), 202 (3) (M*-2SiMe₃), 161 (20) $(HN(SiMe_3)_2), 146 (100) (HN(SiMe_3)_2-Me), 130 (10)$ (HN(SiMe₃)₂-2Me-H), 74 (9) (HSiMe₃). IR (KBr pellet/Nujol mull): v(Al-H) range, $1882/1880 \text{ cm}^{-1}$. We note that these Al-H stretching frequencies significantly differ from that of a weak band at 1790 cm⁻¹ originally reported for 1 [18]. In the present study, the medium intensity band at about 1880 cm⁻¹ was reproducible, but its intensity was decreasing fast in the course of measurements due to deterioration of the sample. At this point, we are inclined to think that the band reported earlier might have been recorded for a significantly decayed sample.

Reactions of $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ with $HNMe_2$. Isolation of $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N-(SiMe_3)_2$ (**2**)

0.10 g of **1** (0.14 mmol) was dissolved in about 10 mL of toluene and the reaction flask was freezepump-thawed three times. Onto this, using a calibrated vacuum line, 0.29 mmol of HNMe₂ was deposited at -78° C. The mixture was stirred at room temperature overnight and non-condensables, H₂, were measured, 0.04 mmol. The solution was then stored for a few days at -30° C. At the end of this period, the volatiles were removed yielding an oil/solid product. IR (neat): weak to medium band in the v(N–H) range at 3310 cm^{-1} ; medium band in the v(Al–H) range at 1833 cm^{-1} . A toluene-d₈ NMR sample of this product was run immediately, 1 day, 2 weeks and 7 weeks after preparation.

Immediately: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (9) (HN(SiMe₃)₂), 0.27 (23), 0.31 (24), 0.33 (100); NMe₂ region: δ 1.88 (9), 1.89 (9) and several small intensity peaks (<1) in this region at 2.29, 2.32, 2.41, 2.42, 2.51, 2.60, 2.76; AlH region: δ 4.0 (very broad), 4.51. ¹³C{¹H} NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (7) (HN(SiMe₃)₂), 5.0 (3), 6.2 (100), 6.5 (16), 6.8 (4); NMe₂ region: δ 37.9 (24), 40.4 (1), 41.6 (2), 42.0 (3), 43.2 (2), 43.5 (7).

1 day after: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (100) (HN(SiMe₃)₂), 0.27 (50), 0.31 (80), 0.33 (35); NMe₂ region: δ 1.88 (1), 1.89 (1), 2.42 (15), 2.51 (1), 2.60 (8), 2.76 (2); no unequivocally measurable broad feature in the AlH region except for the sharp resonance at δ 4.51. ¹³C{¹H} NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (90) (HN(SiMe₃)₂), 4.9 (55), 6.2 (70), 6.5 (100), 6.8 (14); NMe₂ region: δ 37.9 (13), 40.4 (15), 41.6 (5), 42.0 (10), 43.2 (10), 43.5 (70).

2 weeks after: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (100) (HN(SiMe₃)₂), 0.27 (55), 0.31 (83), 0.33 (6); NMe₂ region: δ 1.88 (1), 1.89 (1), 2.42 (16), 2.52 (3), 2.60 (8), 2.76 (4); AlH region: δ 4.1 (broad), 4.51. ¹³C{¹H} NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (83) (HN(SiMe₃)₂), 4.9 (63), 6.2 (35), 6.5 (100), 6.8 (32); NMe₂ region: δ 37.9 (1), 40.4 (20), 41.6 (16), 42.0 (19), 43.2 (17), 43.5 (65).

7 weeks after: The NMR spectra were identical to those obtained after 2 weeks. The oily/solid product was redissolved in a small amount of toluene and, subsequently, volatiles were allowed to evaporate at -30° C in the course of several days. After almost complete removal of volatiles, a small quantity of a colorless crystalline product was isolated. A singlecrystal X-ray structure determination provided $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$ (2). ¹H NMR for a freshly prepared sample (intensity) (group assignment): SiMe₃ region: 0.281 (85), 0.284 (100), 0.29 (63), 0.30 (77), 0.31 (52), 0.32 (71), 0.33 (58); NMe₂ region: δ 2.42 (14), 2.52 (12), 2.66 (25), 2.77 (19), 2.78 (16); AlH region: no discernible feature between δ 3.0–5.0. This sample was also run two days after preparation and showed an even more complex spectrum indicating continuing changes in the solution. IR (KBr pellet): v(Al-H) range, medium to strong band at $1860 \,\mathrm{cm}^{-1}$.

Structural determinations for 1 and 2

Specimens of 1 were obtained in the form of thin colorless needles from recrystallization in toluene at -30°C and mounted in capillaries prior to determination. The systematic absences in the diffraction data were consistent with monoclinic space groups $P2_1/m$ and $P2_1$ but only the latter yielded computationally stable results and refinement. The structure was solved using direct methods, completed by subsequent difference Fourier syntheses and refined by full-matrix least-square procedures. All nonhydrogen atoms were refined with anisotropic displacement coefficients. All C-hydrogen atoms were treated as idealized contributions. The Al-hydrogen atoms were located from the difference map and were refined with fixed thermal parameters and fixed Al-H distances, 1.727(1) A. The geometry of the {Al-H-Al-H} ring was not constrained. There are two symmetry independent, but chemically similar, molecules in the asymmetric unit and the thermal ellipsoid diagram of molecule 1 is shown in Fig. 1. The thermal ellipsoid diagram of molecule 2 is available in the Supporting Information. Specimens of 2 were obtained as blocky colorless crystals from slow evaporation of toluene at -30°C and mounted in capillaries prior to determination. The data were consistent with the monoclinic space group $P2_1/n$. The structure was solved using direct methods, completed by subsequent difference Fourier syntheses and refined by full-matrix



Fig. 1. Thermal ellipsoid diagram (30% probability ellipsoids) showing the molecular structure of 1 (independent molecule 1). All C-hydrogen atoms are omitted for clarity.

least-square procedures. Semi-empirical absorption corrections were not required because there was less than 10% variation in the integrated Ψ -scan intensity data. The Si–N distances were restrained to an average N–Si distance of 1.74 Å. All non-hydrogen atoms were refined with anisotropic displacement coefficients. The hydrogen atom on Al(1) was placed in an idealized position with the fixed Al–H distance of 1.50 Å. All other hydrogen atoms were treated as idealized contributions. The residuals for **2** are rather high due to marginal quality of the specimen. However, the metric parameters and their esd's around aluminum atoms appear to be of acceptable quality. The thermal ellipsoid diagram of **2** is shown in Fig. 2. Details of the



Fig. 2. Thermal ellipsoid diagram (30% probability ellipsoids) showing the molecular structure of **2**. All C-hydrogen atoms are omitted for clarity.

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data collection for **1** and **2** are summarized in Table 1, and Table 2 shows selected bond distances and angles.

RESULTS AND DISCUSSION

Bis(bis(trimethylsilyl)amino)alane

 $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (1) was obtained from disproportionation of the based-stabilized monomeric aminoalane $[H_2AlN(SiMe_3)_2] \cdot NMe_3$ as described by the following idealized equation [18]:

$$2[H_{2}AIN(SiMe_{3})_{2}] \cdot NMe_{3} \xrightarrow{\text{tenda}} H_{3}AI \cdot NMe_{3} + 1/2\{[(Me_{3}Si)_{2}N]_{2}Al(\mu-H)\}_{2} \quad (1)$$

$$\downarrow Al + 3/2H_{2} + NMe_{3}$$

The anticipated formation of the alane trimethylamine byproduct, $H_3Al \cdot NMe_3$, would have been associated with its decomposition under toluene reflux conditions and precipitation of elemental aluminum [25], which was indeed observed. We found this disproportionation reaction to be crucially dependent on the substrate's concentration. For example, dilute toluene solutions did not show signs of the precipitation of elemental aluminum even after a several day-long reflux. On the other hand, appropriately concentrated solutions appeared to react as above in the course of several hours while intermediate removal of some toluene by evacuation accelerated the reaction's progress and resulted in increased yields. The isolation of **1**, after filtering out aluminum, was accomplished by low temperature recrystallization from hexane in which it was much less soluble than was unreacted $[H_2AIN(SiMe_3)_2] \cdot NMe_3$.

The characterization data acquired for 1 in this study were consistent with its chemical make-up as originally reported [18]. In particular, the mass spectrum showed the parent ion for the dimer and other logically derived fragmentation ions. A few higher than dimer m/e fragments of extremely low intensity (<1%) were also detected. This indicated that the dimeric association via H-bridges generally survived the heated probe and electron impact conditions in the MS experiment. The ¹H and ¹³C{¹H} NMR spectra were in agreement with the original NMR data for 1 and, based on their simplicity, supported a symmetrical environment for the N(SiMe₃)₂ groups while excluding a possible rigid, N-bonded structure.

The crystallographic determination for **1** provided two symmetry independent, but chemically similar, molecules in the asymmetric unit. Fig. 1 shows the structure of one of the molecules. The molecule of **1** is a H-bridged dimer which is structurally very similar although not isomorphous with the H-bridged dimer bis(2,2,6,6-tetramethylpiperidino)alane, $[HAl(tmp)_2]_2$ [15], or related F-bridged dimer $[(tmp)_2AlF]_2$ [26]. For example, the wide average N–Al–N angle in **1**, 124.6°, can be compared with the same angles in $[HAl(tmp)_2]_2$

	1	2
Molecular formula	$C_{24}H_{74}Al_2N_4Si_8$	$C_{18}H_{55}Al_2N_5Si_4$
Formula weight	697.55	507.99
Crystal system	monoclinic	monoclinic
Space group	P2 ₁	$P2_1/n$
a (Å)	13.7119(2)	9.1715(5)
b (Å)	18.3400(3)	22.9239(13)
<i>c</i> (Å)	17.8971(4)	15.0291(9)
β (°)	91.4750(9)	96.088(2)
$V(Å^3)$	4499.20(18)	3139.9(3)
Ζ	4	4
$\mu (\mathrm{mm}^{-1})$	0.297	0.260
Temperature (K)	223(2)	198(2)
D_{calcd} (g/cm ³)	1.030	1.075
Crystal dimensions (mm)	$0.10 \times 0.10 \times 0.10$	$0.40 \times 0.35 \times 0.25$
Θ range for data collection (°)	1.14-28.21	1.63-22.50
No. of reflections collected	29387	7735
Independent reflections	$17056 (R_{int} = 0.0584)$	$3809 (R_{\rm int} = 0.1028)$
Data/restraints/parameters	17056/9/697	3499/5/266
$R[I > 2\sigma(I)];^{\mathrm{a}} \mathrm{wR2}^{\mathrm{b}}$	0.0596; 0.1136	0.1220; 0.2918
R (all data); ^a wR2 ^b	0.1110; 0.1356	0.1708; 0.3411
Goodness-of-fit ^c	1.027	0.975
Final max/min $\Delta \rho$ (e/Å ⁻³)	0.320/-0.337	0.774/-0.923

Table 1. Crystallographic data and measurements for 1 and 2

^a $R = \Sigma \Delta / \Sigma(F_0), \Delta = |F_0| - |F_c|.$

^bwR2 = $\Sigma[w(F_0^2 - F_c^2)^2] / \Sigma[(wF_0^2)^2]^{1/2}$.

^cGooF = $[\Sigma[w(|F_0| - |F_c|)^2]/(n-p)]^{1/2}$.

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Table 2. Selected bond distances (Å) and angles (°) for 1 and 2 with estimated standard deviations in parentheses

1		2	
Bond lengths			
Al-exo-N (av)	1.824	Al(1)-exo- $N(3)$	1.836(4)
Al-exo-N; min/max	1.811(4)/1.844(4)	Al(2)-exo- $N(5)$	1.842(4)
		Al(2)-exo- $N(4)$	1.782(8)
		Al(1)-endo- $N(2)$	1.966(8)
		Al(1)-endo-N(1);	1.948(7)
		Al(2)-endo- $N(1)$	1.985(8)
		Al(2)-endo- $N(2)$	1.987(7)
Al–endo-H	1.727(1)	Al-exo-H (assumed)	1.50
Al-Al (av)	2.661	Al(1)-Al(2)	2.829(3)
Si-N (av)	1.755	Si–N (av)	1.743
Si-N; min/max	1.749(5)/1.765(5)	Si-N; min/max	1.7426(10)/1.7430(10)
Si-C (av)	1.874	Si-C (av)	1.87
Si-C; min/max	1.850(7)/1.900(6)	Si-C; min/max	1.834(14)/1.889(10)
Bond angles			
N-Al-N (av)	124.6	N(1)-Al(1)-N(2)	86.1(3)
N-Al-N; min/max	124.2(2)/125.1(2)	N(1)-Al(2)-N(2)	84.5(3)
N-Al-Al (av)	117.7	Al(1)-N(1)-Al(2)	92.0(3)
N-Al-Al; min/max	115.19(14)/120.5(2)	Al(1)-N(2)-Al(2)	91.4(3)
Si(2)-N(1)-Al(1)	115.0(2)	N(3)-Al(1)-N(1)	116.4(3)
Si(1)-N(1)-Al(1)	125.9(3)	N(3)–Al(1)–N(2)	122.4(3)
Si(2)-N(1)-Si(1)	118.7(2)	N(4)-Al(2)-N(5)	111.3(3)
		N(4)-Al(2)-N(1)	110.2(4)
		N(4)-Al(2)-N(2)	114.0(4)
		N(5)-Al(2)-N(2)	114.9(4)
		N(5)-Al(2)-N(1)	119.5(3)

126.9(1)° and [(tmp)₂AlF]₂, 128.6(1)° and they all may reflect similar steric demands of the amino groups in these compounds. The environment around each Natom in **1** is planar (2Si, N and Al connected atoms lie in the same plane; sum of relevant angles is close to 360°) and, although it is tempting to associate this property with a mostly $d\Pi(Si)-p\Pi(N)$ interaction in the N(SiMe₃)₂ ligand, a planar environment appears to exist in the similar {2C, N, Al} fragment in [HAl(tmp)₂]₂ which is lacking such an interaction.

The average Al-N bond length in 1, 1.824 Å, belongs to short distances of this type and its magnitude seems to be a consequence of a tetracoordinate Al atom bonded to a sterically congested tricoordinate N atom. This is strikingly supported by comparison with the Al-N distances in the relevant cases of the previously discussed [HAl(tmp)₂]₂, 1.835(3)Å, and $[(tmp)_2AlF]_2$, 1.832(2)Å, as well as of [H(Cl)AlN(Si- Me_{3}_{2} · NMe₃ [19], 1.823(4) A [for Al-N(SiMe_{3})_{2}]. Shorter Al-N distances are found in tricoordinate Al/tricoordinate N structures, for example, monomeric Al[N(SiMe₃)₂]₃, 1.78(2) Å [16], or six-membered planar ring [MeAlN(2,6-iPr₂C₆H₃)]₃, 1.782(4) Å [27], but in the extremely congested monomeric t- $Bu_2AIN(SiPh_3)_2$ this distance is 1.880(4) Å [28]. On the other hand, in tetracoordinate Al/tetracoordinate N ring or cluster structures these lengths typically span the 1.9 to 2.0 Å range, for example, as in cubane (PhAlNPh)₄, 1.914(5) Å [29], dimer [(Me₃Si)₂AlNH₂]₂, 1.955 Å [30] and trimer (*t*-Bu₂AlNH₂)₃, 2.008 Å [31], although in the dimer {[(Me₃Si)₂N]₂AlNH₂}₂ this bond length is much shorter, 1.841 Å (av) [32]. These trends are illustrated by the structure of (Me₃Si)₂N (Me₂N)Al(μ -NMe₂)₂Al(H)N(SiMe₃)₂ (2) (*vide infra*) that contains Al atoms connected to both tricoordinate N atoms (terminal congested N(SiMe₃)₂ and noncongested NMe₂) and tetracoordinate N atoms (bridging NMe₂).

The Al-H distance of 1.727(1) Å in 1 is one of the longest among similar symmetrical Al-H bridging distances, possibly indicating a loose association of the monomers in the solid state. However, this can not be reconciled in a straightforward way with the dimer parent ion in the gas phase detected by mass spectrometry. This distance can be compared with the average Al-H lengths in the previously discussed symmetrical dimer [HAl(tmp)₂]₂, 1.68 Å or trimer (t-Bu₂AlH)₃, 1.726(5) Å [33]. For the unsymmetrically Hbridged dimer of the $[H_3Al \cdot L]_2$ type of alane adducts, [H₃Al · N(Me₂)CH₂CH₂CH₂Cl]₂, the following Al-H distances are found that span almost the entire range of observable distances of this type, namely, two different ring distances, 1.84(3) and 1.99(5) Å, and two different terminal distances, 1.20(7) and 1.40(6) Å [34]. Of particular interest also is the average Al-Al distance of 2.661 Å. It can be compared with this separation in other symmetrical dimers such as $(HAIMe_2)_2$, 2.62 Å [35] and $[HAI(tmp)_2]_2$, 2.680(2) Å. More importantly, this distance is in the range of the Al–Al bonding distances in structurally authenticated, neutral, monomeric dialanes $[(Me_3Si)_2CH]_4Al_2$, 2.660(1) Å [36] and $[(i-Pr_3C_6H_2)]_4Al_2$, 2.647(3) Å [37] or tetrameric cluster $[AI(C_5Me_5)]_4$, 2.769 Å (av) [38]. Based on that, some bonding interaction along the Al–Al axis is thus probable in **1**.

A 1:1 ratio reaction of 1 and HNMe₂ was performed to test preferences of the two possibly competing reactions, namely, aminolysis at the Al-H site with the formation of dihydrogen and transamination at the $Al - N(SiMe_3)_2 \quad site(s) \quad with \quad the \quad formation$ of HN(SiMe₃)₂. These types of reactions were observed to occur simultaneously in the combination of $[H_2AlN(SiMe_3)_2] \cdot NMe_3$ and NH_3 , and yielded a rare benzene soluble polymeric precursor that was used to make transparent AIN coatings on alumina substrates [18]. Surprisingly, only minute quantities of H_2 were measured several hours past addition indicating very slow aminolysis. This was further supported by an IR spectrum for raw products that showed a N-H stretching band at 3310 cm⁻¹ consistent with coordinated $HNMe_2$ by 1 at this stage of reaction. The NMR spectra for the reaction mixture were run in the course of several weeks following addition and showed a multitude of slowly formed products. This was accompanied by increased quantities of evolved H_2 (sharp ¹H NMR resonance at δ 4.51 [39]) and HN(SiMe₃)₂ consistent with a relatively slow aminolysis and transamination in the system, respectively.

Compound **2** was isolated in small quantities after several days of a low temperature storage of the reaction mixture accompanied by a slow evaporation of volatiles. The NMR data obtained for a fresh solution of **2** in toluene-d₈ were complex and subject to changes with time. These changes might be indicative of slow equilibration processes and formation of more stable symmetrical products in the solution but, also of some on-going chemical interactions. Interestingly, the IR spectrum for the freshly isolated product showed only a single, well defined but, alas, broad band in the v(Al-H) range at 1860 cm⁻¹.

The molecular structure of 2 is shown in Fig. 2. It features a puckered {Al-N-Al-N} ring with unsymmetrical (different) ligands on the aluminum atoms, and can be visualized as a Me₂N-bridged, two-site adduct of the different monomeric aminoalanes $Al(NMe_2)_2[N(SiMe_3)_2]$ and $HAl(NMe_2)[N(SiMe_3)_2]$. The N(SiMe₃)₂ groups on two different Al ring atoms are in the *cis* position to each other. Potentially increased steric congestion due to the cis configuration is apparently counterbalanced by ring puckering, which has the effect of moving apart the $N(SiMe_3)_2$ groups on the congested side of the ring and getting the neighboring small H and NMe2 ligands closer on the other side of the ring with a concurrent decrease of the Al-Al distance. The latter distance of 2.829(3) Å seems to be, however, outside the range of any significant aluminum–aluminum bonding interaction (*vide supra*). The ring puckering as defined by the angle between the N(1)–Al(1)–N(2) and N(1)–Al(2)–N(2) planes amounts to 25.5°. The N and Al atoms in the ring are four-coordinate; although the hydrogen atom is not resolved on Al(1), its presence is supported by both structural [pyramidal Al(1) atom] and chemical evidence [IR band in the v(Al–H) range at 1860 cm⁻¹].

Despite the relatively high values of the residuals for 2, the quality of the numerical data is good enough to address some of the molecule's structural aspects. The aluminum-nitrogen bonds in 2 represent a comprehensive range of bond configurations including ring and different exocyclic bonds, all in one molecule. The average Al-N distance in the ring (Al-endo- NMe_2), 1.972 Å, can be compared with the average distances of this type in some of the Me₂N-bridged dimers such as [Al(NMe₂)₃]₂, 1.965 Å [14] (or 1.970 Å [13]) and [HAl(NMe₂)₂]₂, 1.966Å [13] or trimer (H₂AlNMe₂)₃, 1.950 Å [13]. The Al-exo-NMe₂ distance of 1.782(8) A in 2 belongs, in general, to very short Al-N bond lengths. For example, the following Al-exo-NMe₂ distances are found in the dimers [Al(NMe₂)₃]₂, 1.800 Å (av) [15] [or 1.814 Å (av) [13]], $[HAl(NMe_2)_2]_2$, 1.804(2) Å [13] and $[(Me_2N)_2Al\{\mu$ -N(H)1-adamantanyl}]₂, 1.793 Å [15], while the apparently shortest to-date Al-N bond lengths are reported for monomeric Al[N(SiMe₃)₂]₃, 1.78(2) Å [16], and sixmembered planar ring [MeAlN(2,6-iPr₂C₆H₃)]₃, 1.782(4) Å [27]. The other exocyclic AlN distance(s) in 2, i.e. Al-exo-N(SiMe₃)₂, 1.839 Å (av), falls well within the range of similar terminal bonds. This is exemplified by comparison of this distance with the respective average lengths in 1, 1.824 Å, {[(Me₃S $i_{2}N_{2}AlNH_{2}_{2}$ 1.841 Å [32], or $\{[(Me_3S$ $i_{2}N_{2}Al(NH_{2})_{3}Al, 1.850 \text{ Å} [32]. The Al-exo-$ N(SiMe₃)₂ lengths are generally longer than the Alexo-NMe₂ lengths and this may reflect the congestion effect of the bulkier N(SiMe₃)₂ group.

In summary, the structure of **2** illustrates the occurrence of both the aminolysis (absence of H on one of the Al atoms) and transamination [singular N(SiMe₂)₂ groups on each Al atom] taking place in the reaction between **1** and HNMe₂. Similar combinations of [H₂AlN(SiMe₃)₂] · NMe₃ and NH₃ were also reported to proceed via concerted ammonolysis and transamination and resulted in a soluble polymeric precursor to aluminum nitride [11]. The data presented here are consistent with complex elimination chemistry in these systems and suggest that the new {[(Me₃Si)₂N]₂Al(μ -H)}₂ may be a valuable precursor for conversion to aluminum nitride materials.

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